PCN	Numl	ber:	2022101	3001	.2		PCN D	ate:	October 14, 2022			
I ITIE '					v Fab site (DMOS6) using qualified Process Technology, Die							
		Revision	, and addit	tio na	ional BOM option for select devices							
Cus	tomer	Contact:		<u>PCN</u>	<u>l Manager</u>		Dept:		Quality Services			
Pro	posed	1 st Ship	Date:	Apr	12, 2023	Sample accept	e reque ed unti		Nov 14, 2022*			
*Sa	mple r	equests	received	a fte	r Oct 14, 2022 wi	ll not be	suppo	rted.				
Cha	nge Ty	pe:										
	Assem	bly Site		Assembly Process				Asser	Assembly Materials			
\boxtimes	Desigr	1		☐ Electrical Specification				Mech	anical Specification			
	Test S	ite		Packing/Shipping/Labeling				Test I	Process			
	Wafer	Bump Sit	е		Wafer Bump Mate	rial		Wafei	Wafer Bump Process			
			₩ Wafer Fab Materials			\boxtimes	Wafer Fab Process					
					☐ Part number change							
		·			PCN Deta	ils						
								•				

Description of Change:

Texas Instruments is pleased to announce the qualification of a new fab & process technology (DMOS6, LBC9) and BOM option for selected devices as listed below in the product affected section. Construction differences are noted below:

С	urrent Fab Site	•	Additional Fab Site				
Current Fab Site	Process	Wafer Diameter	Additional Fab Site	Process	Wafer Diameter		
DL-LIN	PRISM	200 mm	DMOS6	LBC9	300 mm		

The die was also changed as a result of the process change.

Additionally, there will be a BOM/Assembly options introduced for these devices:

Group 1 (DW20) BOM options

T (DWZO) BOM OPCIONS			
	Current	Additional	
Bond wire composition,	Au, 1.15 mils	Cu, 0.96 mil	
Diameter	Au, 1.13 Illis	Cu, 0.90 IIII	
Mount Compound	4042500	4147858	
Mold Compound	4205694	4211880	
Probe Site	Not in Process flow	CDPR	

Group 2 (DW24) BOM options

	Current	Additional
Bond wire composition, Diameter	Au, 1.15 mils	Cu, 0.96 mil
Probe Site	Not in Process flow	CDPR

Tube and some G4 versions of the devices are included in EOL notice PDN# 20221013002.3

Reason for Change:

These changes are part of our multiyear plan to transition products from our 150-milimeter factories to newer, more efficient manufacturing processes and technologies, underscoring our commitment to product longevity and supply continuity.

Anticipated impact on Form, Fit, Function, Quality or Reliability (positive / negative):

None

Impact on Environmental Ratings

Checked boxes indicate the status of environmental ratings following implementation of this

change. If below boxes are checked, there are no changes to the associated environmental ratings.

RoHS	REACH	Green Status	IEC 62474
⊠ No Change	☑ No Change	⊠ No Change	☑ No Change

Changes to product identification resulting from this PCN:

Fab Site Information:

Chip Site	Chip Site Origin Code (20L)	Chip Site Country Code (21L)	Chip Site City
SH-BIP-1	DLN	USA	Dallas
DMOS6	DM6	USA	Dallas

Die Rev:

Current	New			
Die Rev [2P]	Die Rev [2P]			
A,B,C	A			

Sample product shipping label (not actual product label)



OPT: LBL: 5A (L)TO:1750



(1P) \$N74L\$07N\$R (Q) 2000 (D) 0336 (31T)LOT: 3959047MLA (4W) TKY(1T) 7523483SI2 (P) (2P) REV: (V) 0033317 (20L) CSO: SHE (21L) CCO-USA (22L) ASO: MLA (23L) ACO: MYS

Product Affected:

Group 1 Device list (DW20)

TPIC6595DWR TPIC6596DWRG4 TPIC6B595DWR TPIC6B596DWR

Group 2 Device list (DW24)

TPIC6A595DWR TPIC6A596DWRG4

For alternate parts with similar or improved performance, please visit the product page on ti.com.



Automotive New Product Qualification Summary (As per AEC-Q100 and JEDEC Guidelines)

TPIC6x59xDW Qualification Approved 16-Sept-2022

Product Attributes

Attributes	Qual Device: TPIC6595DWR	Qual Device: TPIC6A595DWR	Qual Device: TPIC6596DWRG4	Qual Device: TPIC6B595DWR	Qual Device: TPIC6B596DWR	Qual Device: TPIC6A596DWRG4	QBS Process Reference: LMR33630CQRNXRQ1	QBS Package Reference: AMC1305M25QDWRQ1
Automotive Grade Level	Grade 1	Grade 1	Grade 1	Grade 1	Grade 1	Grade 1	Grade 1	Grade 1
Operating Temp Range	-40C to 125C	-40C to 125C	-40C to 125C	-40C to 125C	-40C to 125C	-40C to 125C	-40C to 125C	-40 to +125 C
Product Function	Power Management	Power Management	Power Management	Power Management	Power Management	Power Management	Power Management	Signal Chain
Wafer Fab Supplier	DMOS6	DMOS6	DMOS6	DMOS6	DMOS6	DMOS6	DMOS6	AIZU, DMOS5
Die Revision	A0	A0	A0	A0	A0	A0	В	C, F
Assembly Site	TAI	TAI	TAI	TAI	TAI	TAI	CDAT	TAI
Package Type	SOIC	SOIC	SOIC	SOIC	SOIC	SOIC	VQFN-HR	SOIC
Package Designator	DW	DW	DW	DW	DW	DW	RNX	DW
Ball/Lead Count	20	24	20	20	20	24	12	16

- QBS: Qual By Similarity

- Qual Device TPIC6595DWR is qualified at MSL1 260C
 Qual Device TPIC6595DWR is qualified at MSL1 260C
 Qual Device TPIC6596DWRG4 is qualified at MSL1 260C
 Qual Device TPIC6596DWRG4 is qualified at MSL1 260C
- Qual Device TPIC6B596DWR is qualified at MSL1 260C
 Qual Device TPIC6A596DWRG4 is qualified at MSL1 260C

Qualification Results

Data Displayed as: Number of lots / Total sample size / Total failed

							Data Diopi	ayea as. Ivallib	er or iota / rotar	Jumple Size 7 1	otal lallea			
Туре	#	Test Spec	Min Lot Qty	SS/ Lot	Test Name / Condition	Duration	Qual Device: TPIC6595DWR	Qual Device: TPIC6A595DWR	Qual Device: TPIC6596DWRG4	Qual Device: TPIC6B595DWR	Qual Device: TPIC6B596DWR	Qual Device: TPIC6A596DWRG4	QB\$ Process Reference: LMR33630CQRNXRQ1	QBS Package Reference: AMC1305M25QDWRQ1
Test Group	A – Ac	celerated Er	vironm	ent Str	ess Tests									
PC	A1	JEDEC J-STD- 020 JESD22- A113	60	231	Automotive Preconditioning	Level 1- 260C		-	-		-	Pass	-	-
PC	A1	JEDEC J-STD- 020 JESD22- A113	3	231	Automotive Preconditioning	Level 2- 260C	-	-	-	-	-	-	Pass	-
PC	A1	JEDEC J-STD- 020 JESD22- A113	3	231	Automotive Preconditioning	Level 3- 260C	-	-	-	-	-	-	-	Pass
bHAST	A2	JEDEC JESD22- A101	3	77	Biased HAST, 130C/85%RH	96 Hours	-	-	-	-	-	3/231/0	-	3/231/0
bHAST	A2	JEDEC JESD22- A101	3	77	Biased HAST, 110C/85%RH	264 Hours	-	-	-	-	-	-	3/231/0	-
uHAST	А3	JEDEC JESD22- A102	3	77	Unbiased HAST, 130C/85%RH	96 Hours	-	-	-	-	-	3/231/0	-	-
uHAST	А3	JEDEC JESD22- A102	3	77	Unbiased HAST, 110C/85%RH	264 Hours	-	-	-	-	-	-	3/231/0	-
AC		JEDEC JESD22- A102	3	77	Autoclave 121C	96 Hours	-	-	-	-	-	-	-	3/231/0
тс	A4	JEDEC JESD22- A104 and Appendix 3	3	77	Temperature Cycle, -65/150C	500 Cycles	-	-	-	-	-	3/231/0	3/231/0	3/231/0
PTC	A5	JEDEC JESD22- A105	1	45	Power Temperature Cycle	1000 Cycles	-	-	-	-	-	1/45/0	-	-
HTSL	Ав	JEDEC JESD22- A103	1	45	High Temp. Storage Life, 150C	1000 Hours	-	-	-	-	-	3/135//0	3/135//0	1/45/0

	р В – AC	ccelerated Lit	eume s	simulat	ion rests									
HTOL	B1	JEDEC JESD22- A108	3	77	Life Test, 125C	1000 Hours	-	-	-	-	-	3/231/0	3/231/0	-
ELFR	B2	AEC Q100- 008	3	800	Early Life Failure Rate, 125C	48 Hours	-		-	-		-	3/2400/0	-
EDR	B3	AEC Q100- 005	3	77	NVM Endurance, Data Retention, and Operational Life	10000 Cycles	-	-	-	-	-	-	3/231/0	-
Test Grou	в C – Pa	ckage Asser	nbly Int	tearity 1	Tests									
WBS	C1	AEC Q100- 001	1	30	Bond Shear (Cpk>1.87)	Wires	-			-		1/30/0	N/A	3/90/0
WBP	C2	MIL- STD883 Method 2011	1	30	Bond Pull (Cpk>1.67)	Wires	-		-	-	-	1/30/0	N/A	3/90/0
SD	C3	JEDEC JESD22- B102	1	15	Surface Mount Solderability >95% Lead Coverage	15	-		-	-	-	-	1/15/0	1/15/0
PD	C4	JEDEC JESD22- B100 and B108	3	10	Physical Dimensions (Cpk>1.67)	30 units	-	-	-	-	-	3/90/0	3/90/0	-
SBS	C5	AEC Q100- 010	3	50	Solder Ball Shear (Cpk>1.67)	Solder Balls	-	,		•		N/A	N/A	N/A
Ш	C6	JEDEC JESD22- B105	1	50	Lead Integrity	Leads	-	-	-	-	-	N/A	N/A	N/A
rest Grou	P D – DI	e Fabricatior	Reliab	ility le	SES									
EM	D1	JESD81	Reliab -	elity le	Electromigration	-	Completed Per Process Technology Requirements	Completed Per Process Technology Requirements	Completed Per Process Technology Requirements	Completed Per Process Technology Requirements	Completed Per Process Technology Requirements	Completed Per Process Technology Requirements	Completed Per Process Technology Requirements	Completed Per Process Technology Requirements
	D1			-		-	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Technology	Technology
EM	D1	JESD61		- -	Electromigration Time Dependent Dielectric	-	Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Requirements Requirements	Technology Requirements Completed Per Process Technology	Technology Requirements Completed Per Process Technology
TDDB	D1	JESD81 JESD35 JESD80	-	- -	Electromigration Time Dependent Dielectric Breakdown Hot Injection		Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology	Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology	Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology
TDDB HCI	D1 D2 D3	JESD81 JESD85 JESD80 & 28			Electromigration Time Dependent Dielectric Breakdown Hot Injection Carrier Negative Bias Temperature	-	Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Tequirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology	Process Technology Requirements Completed Per Process Technology	Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology	Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Completed Per Process Technology
TDDB HCI NBTI SM	D1 D2 D3 D4 D5	JESD81 JESD85 JESD80 & 28	-	-	Electromigration Time Dependent Dielectric Breakdown Hot Injection Carrier Negative Bias Temperature Instability		Process Technology Requirements Completed Per Process Technology Requirements Completed Fer Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Requirements Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology	Technology Requirements Completed Per Process Technology	Technology Requirements Completed Per Process Technology
TDDB HCI NBTI SM	D1 D2 D3 D4 D5	JESD85 JESD85 JESD80 & 28	-	-	Electromigration Time Dependent Dielectric Breakdown Hot Injection Carrier Negative Bias Temperature Instability		Process Technology Requirements Completed Per Process Technology Requirements Completed Fer Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Requirements Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology	Technology Requirements Completed Per Process Technology	Technology Requirements Completed Per Process Technology
TDDB HCI NBTI SM	D1 D2 D3 D4 D5	JESD81 JESD85 JESD80 & 28	-	-	Electromigration Time Dependent Dielectric Breakdown Hot Injection Carrier Negative Bias Temperature Instability		Process Technology Requirements Completed Per Process Technology Requirements Completed Fer Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Requirements Completed Per Process Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Requirements Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology Technology	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements Technology Technology	Technology Requirements Completed Per Process Technology	Technology Requirements Completed Per Process Technology
TDDB HCI NBTI SM	D1 D2 D3 D4 D5	JESD81 JESD80 8.28	·	Tests	Electromigration Time Dependent Dielectric Breakdown Hot Injection Carrier Negative Bias Temperature Instability Stress Migration	-	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Technology Requirements Completed Per Process Technology Requirements	Technology Requirements Completed Per Process Technology
TDDB HCI NBTI SM Test Grou	D1 D2 D3 D4 D5 E2	JESD81 JESD85 JESD80 & 28	ication 1	Tests	Electromigration Time Dependent Dielectric Breakdown Hot Injection Carrier Negative Bias Temperature Instability Stress Migration	2500 V	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements	Process Technology Requirements Completed Per Process Technology Requirements Technology Requirements Technology Requirements	Technology Requirements Completed Per Process Technology Requirements	Technology Requirements Completed Per Process Technology

⁻ Preconditioning was performed for Autoclave, Unbiased HAST, THB/Biased HAST, Temperature Cycle, Thermal Shock, and HTSL, as applicable

TI Qualification ID: R-NPD-2202-065



TI Information **Select Disclosure**

Automotive Product Qualification Summary (As per AEC-Q100 and JEDEC Guidelines)

LBC9 MetDCU with 1.0 mil Cu wire in TITL SOIC PKG Approved 13-Sept-2022

Product Attributes

Attributes	Qual Device: <u>TPIC6A596DWRG4</u>
Automotive Grade Level	Grade 1
Operating Temp Range	-40 to +125 C
Product Function	Power Management
Wafer Fab Supplier	DMOS6
Die Revision	A0
Assembly Site	TAI
Package Type	SOIC
Package Designator	DW
Ball/Lead Count	24

⁻ QBS: Qual By Similarity

⁻ Preconducting was performed for Autoclave, Unbiased FAST, I His/biased FAST, I emperature Cycle, I nermal Shock, and HTSL, as applicable
- The following are equivalent HTDL options based on an activation energy of 0.7eV: 152C/Ik Hours, and 150C/300 Hours, and 155C/240 Hours
- The following are equivalent HTSL options based on an activation energy of 0.7eV: 150C/1k Hours, and 170C/420 Hours
- The following are equivalent Temp Cycle options per JESD47: -55C/125C/700 Cycles and -65C/150C/500 Cycles
- The following are equivalent Temp Cycle options per JESD47: -55C/125C/700 Cycles and -65C/150C/500 Cycles
- Qualify and Environmental data is available at TI's external Web site: http://www.ti.com/
- Green/Pb-free Status:
- Qualified Pb-Free(SMT) and Green

⁻ Qual Device TPS22919QDCKRQ1 is qualified at LEVEL1-260C

Qualification Results Data Displayed as: Number of lots / Total sample size / Total failed

Туј	pe #	Test Spec	Min Lot Qty	SS/Lot	Test Name / Condition	Duration	Qual Device: TPIC6A596DWRG4
		Test Gr	oup A – Accelera	ted Enviro	onment Stress Tests		
P	C A	-	3	22	SAM Analysis, Pre Stress	Completed	3/66/0
P	C A	JEDEC J-STD-020 JESD22- A113	3	77	Preconditioning	Level 2-260C	No fails
P	C A	-	3	22	SAM Analysis, Post Stress	Completed	3/66/0
HA	ST A2	2 JEDEC JESD22-A110	3	77	Biased HAST, 130C/85%RH	96 Hours	3/231/0
HA	ST A	-	3	1	Cross Section, Post bHAST 96 Hours	Completed	3/3/0
HA	ST A2	-	3	30	Wire Bond Shear, Post bHast, 96 Hours	Wires	3/90/0
HA	ST A	-	3	30	Bond Pull over Stitch, post bHAST, 96 Hours	Wires	3/90/0
HA	ST A	-	- 3 30 Bond Pull over Ball, Post bHAST, 96 Hours			Wires	3/90/0
HA	ST A	JEDEC JESD22-A110	3	77	Biased HAST, 130C/85%RH	192 Hours	3/210/0
HA	ST A	-	3	1	Cross Section, Post bHAST 192 Hours	Completed	3/3/0
HA	ST A2	-	3	22	SAM Analysis, Post bHAST, 192 Hours	Completed	3/66/0
HA	ST A	-	3	30	Wire Bond Shear, Post bHast, 192 Hours	Wires	3/90/0
HA	ST A	-	3	30	Bond Pull over Stitch, post bHAST, 192 Hours	Wires	3/90/0
HA	ST A		3	30	Bond Pull over Ball, Post bHAST, 192 Hours	Wires	3/90/0
TO	C A	JEDEC JESD22-A104 and Appendix 3	3	77	Temperature Cycle, -65/150C	500 Cycles	3/231/0
TO	C A	-	3	1	Cross Section, Post T/C 500 Cycles	Completed	3/3/0
T	C A	-	3	22	SAM Analysis, Post T/C, 500 Cycles	Completed	3/66/0
Т	C A	-	3	30	Wire Bond Shear, Post T/C 500 Cycles	Wires	3/90/0
Т	C A	-	3	30	Bond Pull over Stitch Post T/C 500 Cycles	Wires	3/90/0
TO	C A		3	30	Bond Pull over Ball Post T/C 500 Cycles	Wires	3/90/0

Туре	#	Test Spec	Min Lot Qty	SS/Lot	Test Name / Condition	Duration	Qual Device: TPIC6A596DWRG4
TC	A4	JEDEC JESD22-A104 and Appendix 3	3	77	Temperature Cycle, -65/150C	1000 Cycles	3/210/0
TC	A4	-	3	1	Cross Section, Post T/C 1000 Cycles	Completed	3/3/0
TC	A4	-	3	22	SAM Analysis, Post T/C, 1000 Cycles	Completed	3/66/0
TC	A4	•	3	30	Wire Bond Shear, Post T/C 1000 Cycles	Wires	3/90/0
TC	A4	-	3	30	Bond Pull over Stitch, Post T/C, 1000 Cycles	Wires	3/90/0
TC	A4	-	3	30	Bond Pull over Ball, Post T/C, 1000 Cycles	Wires	3/90/0
PTC	A5	JEDEC JESD22-A105	1	45	Power Temperature Cycle -40/125C	1000 Cycles	1/45/0
PTC	A5	JEDEC JESD22-A105	1	45	Power Temperature Cycle -40/125C	2000 Cycles	1/45/0
HTSL	A6	JEDEC JESD22-A103	3	45	High Temp Storage Bake 150C	1000 Hours	3/135/0
HTSL	A6	-	3	1	Cross Section, Post HTSL 1000 Hours	Completed	3/3/0
HTSL	A6	JEDEC JESD22-A103	3	44	High Temp Storage Bake 150C	2000 Hours	3/132/0
HTSL	A6	-	3	1	Cross Section, Post HTSL 2000 Hours	Completed	3/3/0

ı	Test Group C – Package Assembly Integrity Tests							
	WBS	C1	AEC Q100-001	3	30	Wire Bond Shear, Cpk>1.67	Wires	3/30/0
	WBP	C2	MIL-STD883 Method 2011	3	30	Bond Pull over Ball, Cpk >1.67	Wires	3/30/0

A1 (PC): Preconditioning:

Performed for THB, Biased HAST, AC, uHAST, TC & PTC samples, as applicable.

Ambient Operating Temperature by Automotive Grade Level:

Grade 0 (or E): -40°C to +150°C Grade 1 (or Q): -40°C to +125°C Grade 2 (or T): -40°C to +105°C Grade 3 (or I): -40°C to +85°C

E1 (TEST): Electrical test temperatures of Qual samples (High temperature according to Grade level):

Room/Hot/Cold: HTOL, ED Room/Hot: THB / HAST, TC / PTC, HTSL, ELFR, ESD & LU

Room: AC/uHAST

Green/Pb-free Status:

Qualified Pb-Free(SMT) and Green

TI Qualification ID: R-NPD-2209-054

For questions regarding this notice, e-mails can be sent to the contacts shown below or your local Field Sales Representative.

Location	E-Mail		
WW Change Management Team	PCN www admin_team@list.ti.com		

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